

| L Number | Hits | Search Text | DB | Time stamp |
|----------|------|--|----------|--------------------|
| 1 | 7 | (("5395790") or ("5492858") or ("5541436") | USPAT; | 2002/10/20 19:20 |
| т | , | or ("6054393") or ("6057208") or | US-PGPUB | |
| | | ("6129091") or ("6165854")).PN. | | |
| 4 | 45 | ("pad oxide") with (nitride) with | USPAT; | 2002/10/20 20:04 |
| 4 | 43 | (oxynitride or "oxy nitride" or SiON) | US-PGPUB | |
| 5 | 34 | ("water spot" or "water spots" or "water | USPAT; | 2002/10/20 20:05 |
| ٦ | 34 | mark" or "water marks") and (oxynitride or | US-PGPUB | |
| | | "oxy nitride" or sion) | | |
| _ | 1692 | oxynitride SAME (RTA or "rapid thermal | USPAT; | 2002/07/23 13:07 |
| _ | 1092 | anneal" or plasma) | US-PGPUB | |
| | 769 | | USPAT; | 2002/07/23 13:07 |
| - | 109 | anneal" or plasma)) and photoresist and | US-PGPUB | 2002, 01, 20 20101 |
| | | nitride and oxide | 00 10102 | |
| | 343 | | USPAT; | 2002/10/16 09:36 |
| _ | 343 | anneal" or plasma)) and photoresist and | US-PGPUB | 2002, 10, 10 03.00 |
| | | nitride and oxide) and trench | OB TOLOB | |
| | 71 | ((oxynitride SAME (RTA or "rapid thermal | USPAT; | 2002/10/16 10:06 |
| _ | / 1 | anneal" or annealing)) and photoresist and | US-PGPUB |] |
| | | nitride and oxide) and trench | 00 10102 | - |
| _ | 92 | | USPAT; | 2002/10/16 10:09 |
| _ | 92 | (RTA or "rapid thermal anneal" or | US-PGPUB | |
| | | annealing)) and photoresist and nitride | 00 10102 | Į. |
| | | and oxide) and trench | | |
| | 265 | · · | USPAT; | 2002/10/16 10:11 |
| | 203 | (dense or denser or densified or | US-PGPUB | |
| | | densifying) | 00 20202 | |
| _ | 116 | | USPAT; | 2002/10/16 10:14 |
| - | 110 | (dense or denser or densified or | US-PGPUB | |
| | | densifying) | 00 10102 | |
| _ | 45 | 1 2. | USPAT; | 2002/10/16 10:41 |
| | 43 | (dense or denser or densified or | US-PGPUB | |
| | | densifying)) and (RTP or RTA or anneal or | | |
| | | annealing) | | |
| _ | 6 | , | USPAT | 2002/10/16 11:14 |
| | · · | "5976948" "6083808" "6180466").PN. | | |
| _ | 340 | | USPAT; | 2002/10/16 11:46 |
| | 510 | (RTA or "rapid thermal anneal" or | US-PGPUB | |
| | | annealing)) and (clean or wet or HF or | | } |
| | | BOE) | | |
| _ | 377 | | USPAT; | 2002/10/16 11:52 |
| | 2,, | (anneal or annealing or RTP or thermal)) | US-PGPUB | |
| | | same (oxygen or nitrogen) | | |
| _ | 144 | (((oxynitride or "oxy nitride" or ONO) | USPAT; | 2002/10/16 11:49 |
| | | WITH (anneal or annealing or RTP or | US-PGPUB | |
| | | thermal)) same (oxygen or nitrogen)) and | | |
| | | (ARC or photoresist) | | |